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(12)

EUROPEAN PATENT APPLICATION

(21) Application number: 86302982.3

(51) Int. Cl.⁴: G 02 B 5/20
 G 02 B 5/28, G 02 B 1/10
 H 01 J 29/86, H 01 J 29/89

(22) Date of filing: 21.04.86

(30) Priority: 22.04.85 JP 84662/85

(43) Date of publication of application:
 05.11.86 Bulletin 86/45

(84) Designated Contracting States:
 DE FR GB IT NL

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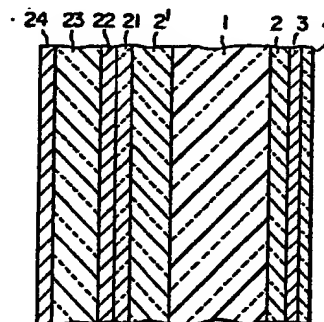
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(54) Light-transmissible plate shielding electromagnetic waves.

(57) A light-transmissible plate having the function of shielding electromagnetic waves comprises a transparent plastic base plate (1), a hard coating layer (2, 2') on the base plate (1), an electroconductive layer (3) on the hard coating layer (2) and a layer (4) having low refractive index on the electroconductive layer (3). The plate (100) can shield electromagnetic waves, and can have high damage resistance even if the plastic constituting the base plate (1) has low surface hardness. Moreover, it is possible to give the plate (100) the function of preventing reflection.

A further anti-reflection film composed of a plurality of layers (21, 22, 23, 24) may be formed on a hard coating layer (2') on the surface opposite to the surface on which the electroconductive layer (3) is provided. The film has excellent adhesion, durability, abrasion resistance, wear resistance, shock resistance, chemical resistance, flexibility, heat resistance, light resistance, weather resistance and static charge resistance, and has excellent properties of shielding electromagnetic waves, eliminating static electricity and preventing reflection.

FIG. 8.



TITLE OF THE INVENTION**LIGHT-TRANSMISSIBLE PLATE SHIELDING
ELECTROMAGNETIC WAVES****BACKGROUND OF THE INVENTION****1. Field of the Invention:**

The present invention relates to a light-transmissible plastic plate which shields
5 electromagnetic waves. More particularly, the present invention relates to a light-transmissible plate capable of effectively shielding deleterious electromagnetic waves which are generated from a display or a Braun tube etc. Moreover, the present invention relates to a light-
10 transmissible plate having durability and the function of reducing reflection.

2. Description of the Prior Art:

Displays of office automation equipment, for example word processors or computers etc., or Braun tubes of
15 game machines or television sets generate deleterious electromagnetic waves. There are some problems due to the electromagnetic waves, which are often pointed out, for example, problems with respect to health and noises which influence other equipment. For instance, it often happens
20 that false signals due to noises come into a computer. It

also happens that noises of a stereo are generated when both the stereo and a television set are operating at the same time.

Many improvements have been carried out to
5 dissolve the problems. One of the improvements is a method of covering the equipment which generate electromagnetic waves, with electroconductive material such as a metal. For example, a cloth capable of shielding electromagnetic waves and an "Eyesaver" (the trade name of a commodity of Chori
10 Kabushiki Kaisha, a Japanese company) are known. The cloth is constructed by adhering carbon onto a fiber with small diameter and then weaving the fiber to form a meshed structure, and the cloth is applied on equipment which generate electromagnetic waves. "Eyesaver" is constructed
15 of glasses and metal wire positioned between the glasses.

However, since the above methods cause a partial intercepting of the ray from a display, it becomes rather difficult for an operator of the equipment to look at the display clearly.

20 A method forming an evaporation coating layer of electroconductive material on a glass base plate is also known. Such a method is disclosed, for example, in Japanese Patent Publication No. SHO 49-18447. However, when the
method is applied to a plastic base plate, the base plate is
25 liable to soften or to melt, and is liable to be injured at

the surfac . Therefore, the method can not be applied for manufacturing a light-transmissible plastic plate.

Moreover, with respect to anti-reflection film technology, various forming methods and various structures thereof are disclosed. Japanese Patent Publications No. SHO 59-48702, SHO 59-78301 and SHO 59-78304 disclose a method wherein a hard coating film comprising a polyorganosilane or a hardened film comprising an epoxy resin is formed on a plastic base plate and then an anti-reflection film comprising inorganic material is coated on the above hard coating layer. Japanese Patent Publication No. SHO 56-113101 discloses a structure wherein an anti-reflection film comprising a plurality of oxide compound layers is provided on a plastic base plate. The structure has high hardness at the surface and a satisfactory anti-reflection function, but adhesion between the base plate and the film, heat resistance, shock resistance, hot water resistance and weather resistance thereof are not satisfactory. Japanese Patent Publications No. SHO 45-6193, SHO 59-48702, SHO 59-78301 and SHO 59-78304 disclose other structures including other anti-reflection films, but the adhesion between the base plate and the anti-reflection film in these structures is also unsatisfactory, and the surfaces of anti-reflection films are liable to be damaged. Moreover, the plates are liable to be damaged by water or alcohol, and

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the structures have adhesion problems between the base plate and the film after dipping the plate into hot water and also in severe weather.

Although several conventional technologies have been described, all of these technologies have a problem in connection with adhesion between a hard coating layer provided on a base plate and a layer of anti-reflection film provided on the hard coating layer. Therefore, the anti-reflection film tends to separate from the hard coating layer over a long period of time.

SUMMARY OF THE INVENTION

An object of the present invention is to provide a light-transmissible plate which can shield electromagnetic waves wherein an electroconductive layer is coated on a base plate, even if the base plate is constructed of a plastic material.

Another object of the present invention in one of its aspects is to provide a technology wherein hardness at a surface of the light-transmissible plate can be increased.

A further object of the present invention is to provide a technology wherein the light-transmissible plate can also have a function of anti-reflection.

Still another object of the present invention in another aspect thereof is to provide a light-transmissible plate which includes an anti-reflection film having excellent physical properties in various respects.

To accomplish the above objects, a light-transmissible plate according to the present invention comprises :

10 (1) A light-transmissible plate shielding electromagnetic waves comprising a transparent plastic base plate, a hard coating layer provided on a surface of the base plate, the hard coating layer having scratch resistance, an electroconductive layer provided on the
15 surface of the hard coating layer, and a layer provided on the surface of the electroconductive layer, said layer having a lower refractive index than the refractive index of the electroconductive layer.

 (2) A light-transmissible plate shielding electro-
20 magnetic waves comprising a transparent plastic base

plate, a hard coating layer provided on one surface of the base plate, the hard coating layer having scratch resistance, an electroconductive layer provided on the surface of the hard coating layer, a layer provided on the surface of the electroconductive layer, said layer having a lower refractive index than the refractive index of the electroconductive layer, and an anti-reflection film provided on another surface of the base plate, the anti-reflection film may ^{be} / composed of a plurality of layers.

BRIEF DESCRIPTION OF THE DRAWINGS

The present invention will be better understood from the following detailed description taken with accompanying drawings.

FIG. 1 is a sectional view of a light-transmissible plate having the function of shielding electromagnetic waves and the function of resisting static charge according to one embodiment of the present invention.

Light-transmissible plate 100 is constituted as follows. Hard coating layer 2 is provided on one surface of the transparent base plate 1, and the hard coating layer 2 has scratch resistance. Electroconductive layer 3 is provided on a surface of the hard coating layer 2. Layer 4 is provided on a surface of the electroconductive layer 3, and

layer 4 has a lower refractive index than the refractive index of the electroconductive layer 3. On another surface of base plate 1, hard coating layer 2' having scratch resistance is provided, and an anti-reflection film 4' is provided on the hard coating layer 2'. Numeral 5 shows a portion of an exposed surface of electroconductive layer 3. Light-transmissible plate 100 is disposed so as to direct a surface having electroconductive layer 3 toward a surface generating picture image, for example, a surface of a cathode-ray tube.

FIG. 2 is a plan view of the light-transmissible plate 100 in FIG. 1. Exposed surface 5 of electroconductive layer 3 may be formed either along the entire periphery of the light-transmissible plate 100, or along only a part of the periphery. For shielding electromagnetic waves and/or for eliminating static electricity, a metal frame (not shown) is provided around the plate 100 so as to contact with electroconductive layer 3, or an earthing wire 6 is connected to the electroconductive layer 3. The earthing wire 6 is connected desirably to a corner of electroconductive layer 3.

FIG. 3 - 7 show preferred embodiments according to the present invention in relation to connecting an earthing wire. In FIG. 3, hole 9 is provided through the light-transmissible plate 100, and an earthing

wire 15 is connected theret via metal fitting piece 6a. In the connection, it is desirable to use a metal packing 7. Metal fitting piece 6a is fixed by a fixing means, for example, set screw 10a and nut 10b (FIG.3), or a caulking piece 8 (FIG. 4). Then the portion of the connection is covered by a plastic cover 11. FIG. 5 shows an embodiment wherein metal fitting piece 6a is fixed nearly parallel to light-transmissible plate 100 in plastic cover 11. FIG. 6 shows an embodiment wherein helical insert 12 is fitted into hole 9 and earthing wire 15 is fixed by screw 13 via metal fitting piece 6a. In this case, providing a hole 11a on the cover 11 facilitates removing the screw 13, and the structure is convenient for removing light-transmissible plate 100 from equipment or cleaning the plate 100. FIG. 7 shows an embodiment wherein earthing wire 15 is connected to the plate 100 via adjuster 14a and 14b.

FIG. 8 is a partial sectional view of a light-transmissible plate having an anti-reflection film constituted by a plurality of layers according to a second embodiment of the present invention. On one surface of transparent plastic base plate 1, hard coating layer 2, electroconductive layer 3 and layer 4 having a lower refractive index than the refractive index of electroconductive layer 3 are provided, and on another surface of base plate 1, hard coating layer 2' having

scratch resistance and anti-reflection film 20 are provided. Anti-reflection film 20 is constructed of No. 1 layer 21, No. 2 layer 22, No. 3 layer 23 and No. 4 layer 24.

5 DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

First, the first embodiment of the present invention is described.

A hard coating layer having scratch resistance is provided on a surface of a transparent plastic base plate.

- 10 A plastic constituting the base plate may be any conventional plastic. The transparent base plate means any plastic plate capable of transmitting light. In the case that a light-transmissible plate is used for a display of a word processor etc., it is desirable to apply a base plate
- 15 set to the transmittance of visible rays of 25 - 70% by its own color or dyeing. The fatigue of the eyes of an operator is reduced by the above restriction. The hard coating layer having scratch resistance means a coating layer having high hardness, for example, a layer including
- 20 polyorganosiloxane, silica or alumina, or a coating layer constructed of a hardening paint, for example, an acrylic paint. Although / ^{the} surface of a plastic plate is generally liable to be damaged, characteristics of the surface can be improved by the hard coating layer, and at the same time,
- 25 adhesion of a layer shielding electromagnetic waves is

raised by under-coating the hard coating layer. Most preferably, the hard coating layer consists of a polyorganosiloxane which is produced by heat-condensing after coating methyltrimethoxysilane and vinyltriethoxysilane or after coating hydrolysis compound thereof. Desirable film thickness of the hard coating layer is in the range of about 1 - 10 μm . The hard coating layer including the acrylic is constructed of, for example, a compound crosslinked with an acrylic compound and an ester compound.

10 The acrylic compound is constructed of, for example, methacrylic acid and the ester compound is constructed of, for example, an ester compound produced from an ester and a polyfunctional glycol, for example, pentaerythritol or glycerin.

15 Next, an electroconductive layer is provided on a surface of the hard coating layer. Any material having electroconductivity and capable of transmitting light can be used for the electroconductive layer, but preferably the layer is constructed of a mixture with indium oxide (In_2O_3) and tin oxide (SnO_2). The mixture is also called "ITO" hereinafter in this specification. "ITO" has high electroconductivity, can shield electromagnetic waves effectively and can transmit visible rays. A film thickness of the "ITO" layer may be any thickness as long as the layer

20 can satisfy the above functions. A desirable thickness is

25

in the range of 100 - 3000Å/ ^{° (10-300nm)} If a thickness of more than 300nm is utilized, cracking is liable to occur. The "ITO" layer can be coated by sputtering. Other methods can be applied for forming the "ITO" layer. For example, the "ITO" layer is formed by evaporation coating using plasma due to high-frequency electric discharge in an atmosphere of oxygen and in a temperature condition of less than 150°C, with the assistance of an ion gun.

Next, a layer having a lower refractive index than the refractive index of the electroconductive layer is provided on the surface of the electroconductive layer. Generally, since an electroconductive layer includes metal, the refractive index of the layer is high. For example, the refractive index of the "ITO" layer is about 2.0. As an amount of reflection becomes larger due to the high refractive index, fatigue of the eyes of the operator also becomes larger. Therefore, it is necessary to provide a layer having a low refractive index on the surface of the electroconductive layer, thereby preventing reflection to the light-transmissible plate. The layer having the low refractive index may be any conventional low refractive layer, but desirably the layer is a layer including inorganic silica. The layer including inorganic silica can be formed by sputtering the silica or by vacuum evaporation coating of the silica. The film thickness of the layer may

be any thickness as long as the layer can appropriately prevent reflection.

In the first embodiment of the present invention, the hard coating layer, the electroconductive layer and the layer having the low refractive index are provided on one surface of the base plate, or on both surfaces of the base plate. In providing them on one surface, it is preferable to provide at least the hard coating layer on another surface to prevent damage of the another surface, and more preferably, the anti-reflection layer is provided on a surface of the hard coating layer.

Next the second embodiment of the present invention is described.

In this embodiment, an anti-reflection film composed of a plurality of layers is provided on a surface of the base plate, the surface being an opposite surface to a surface on which the electroconductive layer is provided.

The anti-reflection film is provided on a surface of the hard coating layer which is provided on one surface of the base plate. The film is constructed of No. 1 layer, No. 2 layer, No. 3 layer and No. 4 layer. The No. 1 layer is provided on the surface of the hard coating layer. The principal ingredient of the No. 1 layer is zirconium oxide. The No. 2 layer is provided on the surface of the No. 1 layer, and the principal ingredient of the No. 2 layer is

silicon dioxide. The No. 1 layer becomes a binder between the hard coating layer and the No. 2 layer, and the strength of both adhesions between the hard coating layer and the No. 1 layer and between the No. 1 layer and the No. 2 layer is increased. The No. 2 layer raises the strength of adhesion against both the No. 1 layer and the No. 3 layer. At the same time, if the No. 1 layer and the No. 2 layer are constructed as an equivalent film, the equivalent film can be a film having a middle refractive index, compared with the No. 3 layer having a high refractive index and the No. 4 layer having a low refractive index. The No. 3 layer is provided on a surface of the No. 2 layer, and the principal ingredient of the No. 3 layer is titanium oxide. The No. 4 layer is provided on a surface of the No. 3 layer, and the principal ingredient of the No. 4 layer is silicon dioxide. The equivalent film (No. 1 layer and No. 2 layer) having the middle refractive index, the No. 3 layer having the high index and the No. 4 layer having the low index, constitute the anti-reflection film as a whole, with the film having the excellent function of preventing reflection.

The above anti-reflection film can be coated by vacuum evaporation or sputtering. Vacuum evaporation is better than sputtering. The assistance of an ion beam may be utilized for forming the film. Titanium oxide can be added into the No. 1 layer including zirconium oxide as long

as the effect of the present invention is not reduced. In the same manner, Ta_2O_5 can be added to the No. 3 layer including titanium oxide.

The thickness of the anti-reflection film may be any thickness as long as the film can prevent the reflection of visible rays. Preferable optical film thicknesses are as follows when the design wave length λ_0 is within 450 - 550 nm.

- No. 1 layer; $0.05 - 0.15 \lambda_0$,
- 10 No. 2 layer; $0.05 - 0.15 \lambda_0$,
- No. 3 layer; $0.36 - 0.49 \lambda_0$, and
- No. 4 layer; $0.15 - 0.35 \lambda_0$.

Particularly, the thickness of No. 4 layer is desirably $0.25 \lambda_0$.

15 The anti-reflection film constructed of a plurality of layers is provided on one surface of the plastic base plate, or on both surfaces of the base plate. In providing the film on one surface, it is desirable to provide the hard coating layer on another surface to prevent damage of the other surface. It is also provided that the anti-reflection film may be positioned on one surface of the base plate, and that the hard coating layer and indium oxide-tin oxide layer ("ITO" layer), or the layer including silicon dioxide besides them are provided on another surface. In such a light-transmissible plate, a layer

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having the function of preventing reflection is formed on one surface and a layer having the function of shielding electromagnetic waves is formed on another surface. In a structure in which the "ITO" layer is an outermost layer, 5 the film thickness of the "ITO" layer is preferably formed to a small size, for example, $100 - 500\text{\AA}$, ^(10-50nm) In a structure in which the layer including silicon dioxide is provided on the "ITO" layer, the film thickness of the "ITO" layer is formed to a large size relatively, for example, $500 - 1000\text{\AA}$. ^(50-100nm)

10 In the light-transmissible plate according to the present invention, an earthing means may be connected thereto to eliminate static electricity. In the case that the "ITO" layer is provided, an earthing wire may be connected to the "ITO" layer directly, or continuity via a 15 certain electroconductive piece between the "ITO" layer and the earthing wire may be ensured. As another means, an outer frame constructed of metal may be provided around the plate, and static electricity may be discharged via the frame. Also in this case, the metal frame may preferably 20 come into contact with the "ITO" layer directly, or continuity via a certain electroconductive piece between the metal frame and "ITO" layer may be maintained.

As described in the above, according to the first embodiment of the present invention, providing the hard 25 coating layer on the transparent plastic base plate can

raise the hardness of the light-transmissible plate, thereby providing characteristics of abrasion resistance and wear resistance to the plate, even if the base plate consists of a plastic having low hardness. Providing the
5 electroconductive layer formed on the hard coating layer and the layer having a low refractive index formed on the electroconductive layer, can shield electromagnetic waves, and at the same time can prevent reflection.

According to the second embodiment of the present
10 invention, since the anti-reflection film having excellent static charge resistance is provided on the surface opposite to the surface on which the electroconductive layer is provided, a light-transmissible plate which shields electromagnetic waves can also eliminate static electricity
15 and prevent reflection. Moreover, since the anti-reflection film constructed of a plurality of layers also has excellent strength of adhesion, durability, abrasion resistance, wear resistance, shock resistance, chemical resistance, flexibility, heat resistance, light resistance and weather
20 resistance, excellent optical products can be obtained as a whole.

A representative analysis of components of the electroconductive layer or the anti-reflection film according to the present invention can be carried out by
25 applying Auger electron spectrophotometry. In this method,

an electron beam is irradiated onto a surface of a sample positioned in a high vacuum, and the Auger electron released from the surface is measured by an analyzer with a partition of energy. Conditions of the measurement are as follows.

- 5 analyzer; "JAMP-10S" produced by Nippon Denshi
Kabushiki Kaisha (Japanese company)
degree of vacuum (when measuring an outermost
surface); 1×10^{-7} Pa
degree of vacuum (when measuring in a direction of
10 depth) ; 6×10^{-6} Pa (argon atmosphere)
sampling; to fix a sample on a sample stand
holding an edge of the sample down with
a copper plate
acceleration voltage
15 ; 3.0 kV
current flowing through a sample
; 1×10^{-8} A
diameter of the electron beam
; 1 μ m
20 slit used for the measurement
; No. 5
angle of inclination of a sample
; 40 - 70 degree
- 25

etching condition of Ar ion
acceleration voltage
; 3.0 kV
current flowing through a sample
; 3×10^{-7} A
5 etching speed
: 200Å/min (20nm/min) (when SiO₂)

The light-transmissible plate shielding
electromagnetic waves according to the present invention is
10 effective, particularly when used as a filter for a
television set or a display. As other uses, it is possible
to apply the plate as a lens, and it is also possible to
form it into various shapes, for example, a film, a block,
etc.

15

EXAMPLES

The present invention will be more readily
appreciate from the following detailed description of the
examples.

20 EXAMPLE 1

A polymethacrylate plate on the market is
used as a transparent plastic base plate. (The plate is
"Acrylite" (trade mark) LN-084, produced by Mitsubishi
Rayon Kabushiki Kaisha, colored to gray, thickness; 2 mm.)
25 A mixture of two compounds (one is obtained by hydrolyzing

vinyltriethoxysilan with glacial acetic acid, another is obtained by hydrolyzing methyltriethoxysilane (with glacial acetic acid) is used as a paint for hard coating, as shown in example 1 of Japanese Patent Publication No. SHO 59-114501. A paint for the present invention is made by

5 adding sodium acetate, which is a hardener, to the mixture and then by adding a surface lubricant including silicon to the mixture. The paint is coated on a surface of the base plate with thickness of $2\mu\text{m}$, and it is cured by heating. Thus a hard coating layer is formed.

10 Next, as an electroconductive layer, a mixture of In_2O_3 and SnO_2 is coated on the hard coating layer, and the mixture is coated with film thickness of 700\AA by sputtering. ^(70nm)
The condition of the sputtering is at the same condition as shown in example 7 - 9 of Japanese Patent Publication No. SHO 60-32053. That is, the target utilized is indium-tin alloy, a magnetron -sputtering apparatus is used, the atmosphere is a gas mixture of argon and oxygen (oxygen: 30 vol.%), and the vacuum pressure of the atmosphere is 1×10^{-3} Torr.

20 Next, as a layer having low refractive index, a film constructed of silicon dioxide is formed on the electroconductive layer. The film is formed by electron-beam method, using vacuum evaporation coating

apparatus (BMC-800T, produced by Shinku Kikai Kogy Kabushiki Kaisha). The film thickness is 940\AA (94nm).

On the other surface of the base plate, the same hard coating layer as the above is provided. Then, a film
5 of aluminium oxide and a film of silicon dioxide are formed in order on the hard coating layer, thereby giving a function of hardening the surface and preventing reflection to the plate.

The light-transmissible plate obtained as above
10 has the following functions. Volume of transmission of electromagnetic waves in the frequency of 10 GHz is reduced to about 1/10 volume, compared with only a transparent plastic base plate. When the plate is used as an optical filter for a word processor, it is excellent with respect to
15 preventing reflection, and fatigue of the eyes of the operator is effectively reduced. Hardness of the surface is increased, thereby the plate is tough against abrasion.

EXAMPLE 2

A hard coating layer on the base plate is formed
20 with the same manner as in example 1. Next, a film of silicon dioxide with thickness of 100\AA (10nm) is formed as an undercoating layer on the hard coating layer by sputtering. Then, on the undercoating layer, "ITO" layer (film thickness; 1400\AA (140nm)) coated by sputtering and a film of silicon
25 dioxide coated by vacuum evaporation coating are formed in

the same manner as in example 1. On another surface of the base plate, a hard coating layer is formed in the same manner as in example 1. Then, on the hard coating layer, layers of Y_2O_3 ($\lambda/4$), TiO_2 ($\lambda/2$), SiO_2 ($\lambda/4$) are provided in order. λ is a design wave length.

The light-transmissible plate obtained as the above had the following functions. The volume of transmission of electromagnetic waves in the frequency of 10 GHz is reduced to about 1/22 volume, compared with only a transparent plastic base plate. When the plate is used as an optical filter for a word processor, it is more effective with respect to preventing reflection and preventing abrasion than example 1.

EXAMPLE 3

In the example, a polymethacrylate plate having a hard coating layer thereon, being on the market, is used as a base plate. (The plate is "Acrylite" (trade mark) LN-084, produced by Mitsubishi Rayon Kabushiki Kaisha, colored to gray, thickness; 2 mm.) Other layers, that is, the "ITO" layer and a layer having a low refractive index is formed in the same manner as in example 1. The plate in the example 3 is manufactured to an excellent plate as well as in example 1.

EXAMPLE 4

A polymethacrylate plate ("Acrylite" (trade mark) LN-084, colored to grey, thickness; 2 mm) is used as a base plate. As a paint for hard coating, a mixture of two
5 compounds (one is obtained by hydrolyzing vinyltriethoxysilane with glacial acetic acid, another is obtained by hydrolyzing methyltriethoxysilane with glacial acetic acid) is used, as shown in example 1 of Japanese Patent Publication No. SHO 59-114501. A paint for the present
10 invention was made by adding sodium acetate, which is a hardener, to the mixture, and then by adding surface lubricant including silicon to the mixture.

The paint is coated on both surfaces of the base plate with a thickness of 2 μ m, and then it is cured for 3
15 hours at 90°C. Thus hard coating layers are formed.

Next, the "ITO" layer is coated on the hard coating layer on one surface of the base plate, and then the SiO₂ layer is provided on the "ITO" layer by vacuum evaporation coating. With respect to another hard coating
20 layer on another surface of the base plate, the surface is set in a vacuum evaporation coating tank. After the tank is heated to 60°C and vacuumed to 1×10^{-5} Torr, the surface is cleaned with an Argon ion beam generated from the ion beam generating device of the Kaufman type, under the
25 acceleration voltage condition of 500 V. Then, the

following four layers are formed by electron-beam method, in order, from the surface of the base plate.

(1) No. 1 layer; the principal ingredient of the layer is zirconium oxide, the optical film thickness is about 42 nm, and the vacuum condition when forming the layer is 3×10^{-5} Torr.

(2) No. 2 layer; the principal ingredient of the layer is silicon dioxide, the optical film thickness is about 42 nm, and the vacuum condition when forming the layer is 1×10^{-5} Torr.

(3) No. 3 layer; the principal ingredient of the layer is titanium oxide, the optical film thickness is about 216 nm, and the vacuum condition when forming the layer is 4×10^{-5} Torr.

(4) No. 4 layer; the principal ingredient of the layer is silicon dioxide, the optical film thickness is about 120 nm, and the vacuum condition when forming the layer is 1×10^{-5} Torr.

In the above paragraphs (1) - (4), a design wavelength in accordance with the optical film thicknesses is 480 nm.

The plate obtained in the above manner has a reflection interference color of royal purple, and has an extremely excellent function of preventing reflection whereby the surface reflection factor

at 550 nm is about 0.2%. The plate also has an excellent hardness at the surface. A sheet of polyester fiber, which is formed into a square having a side of 2 cm and which is dropped into water, is positioned on the surface of the plate, a load of 2 Kg is put on the sheet, and then the sheet is moved reciprocally maintaining the above load condition, but there is no abrasion thereon.

An atmospheric exposure test is carried out by exposing the plate outdoors for one month. The result is that there is no break away of the anti-reflection film and no damage of the surface. When the plate is used as an optical filter for a word processor, it is extremely excellent with respect to preventing reflection, and fatigue of eyes of an operator is highly reduced. Durability of the plate is also excellent.

Moreover, the following measurement was carried out with respect to the property of static charge resistance. An electrostatic voltmeter ("Statiron M", produced by Shishido Seidenki Kabushiki Kaisha, Japanese company) is positioned spacedly 53 mm from the front surface of a CRT. The CRT (NEC-KD551K) is connected to a personal computer (PC-9801E, produced by Nihon Denki Kabushiki Kaisha). When the switch of the personal computer is on, the electrostatic potential measured by "Statiron M" is more than 9 kV. Next, the plate according to the present

inv ntion is position d between the CRT and "Statiron M", at
a position 30 mm from "Statiron M". The plate is
grounded. Then, the personal computer was on, but
electrostatic potential measured by "Statiron M" is
5 maintained at 0. The effect of static resistance due to the
plate was extremely excellent.

CLAIMS :

1. A light-transmissible plate for shielding electromagnetic waves characterized in that,

a hard coating layer (2) is provided on a surface of a transparent plastic base plate (1), said hard coating
5 layer having scratch resistance;

an electroconductive layer (3) is provided on the surface of said hard coating layer (2); and

a layer (4) is provided on the surface of said electroconductive layer (3), said layer (4) having a
10 lower refractive index than the refractive index of said electroconductive layer (3).

2. A light-transmissible plate according to claim 1, wherein said electroconductive layer (3) is a layer containing indium oxide and tin oxide.

15 3. A light-transmissible plate according to claim 2, wherein said layer containing indium oxide and tin oxide is formed by sputtering.

4. A light-transmissible plate according to claim 2, wherein said layer containing indium oxide and tin oxide
20 is formed by evaporation coating, said evaporation coating being performed using plasma due to high-frequency electric discharge, in an atmosphere of oxygen and at a temperature of less than 150°C, with the assistance of an ion gun.

5. A light-transmissible plate according to any
25 preceding claim, wherein the film thickness of said electroconductive layer (3) is within the range of 10 to 300nm.

6. A light-transmissible plate according to any preceding claim, wherein said hard coating layer (2) is a layer containing organopolysiloxane.

7. A light-transmissible plate according to any one of claims 1 to 5, wherein said hard coating layer (2) is formed by coating with a hardening paint.

8. A light-transmissible plate according to any preceding claim, wherein said transparent plastic base plate (1) is a coloured plate.

9. A light-transmissible plate according to any preceding claim, wherein said layer (4) having said low refractive index is a layer constructed of inorganic silica.

10. A light-transmissible plate according to claim 9, wherein said layer constructed of inorganic silica is formed by a vacuum evaporation coating.

11. A light-transmissible plate according to any preceding claim, wherein a ground wire (6, 15) is connected to said electroconductive layer (3).

12. A light-transmissible plate according to any preceding claim, wherein an outer frame is provided around said light-transmissible plate, said outer frame extending along the edge of said light-transmissible plate and coming into contact with said electroconductive layer.

13. A light-transmissible plate according to any one of claims 1 to 12, wherein a further hard coating layer (2') is provided on the surface of the transparent

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plastic base plate (1) opposite to the surface bearing the hard coating layer (2).

14. A light-transmissible plate comprising a transparent plastic base plate (1) both sides of which bear
5 layers according to any one of claims 1 to 12.

15. A light-transmissible plate according to any one of claims 1 to 13, having an anti-reflection coating (4':21,22,23,24) on the side of the transparent plastic base plate (1) opposite to the surface bearing the hard
10 coating layer (2).

16. A light-transmissible plate according to claim 15, wherein the anti-reflection coating consists of a plurality of layers (21-24).

17. A light-transmissible plate according to claim 16
15 wherein the anti-reflection coating is applied to a hard coating layer (2') and consists of the following layers -

a first layer (21) provided on a surface of said hard coating layer (2'), the principal ingredient of said first layer (21) being zirconium oxide;

20 a second layer (22) provided on a surface of said first layer (21), the principal ingredient of said second layer (22) being silicon dioxide;

a third layer (23) provided on a surface of said second layer (22), the principal ingredient of said third
25 layer (23) being titanium oxide; and

a fourth layer (24) provided on a surface of said third layer (23), the principal ingredient of said fourth layer (24) being silicon dioxide.

18. A light-transmissible plate according to claim 16 or claim 17, wherein the optical film thicknesses of said first to fourth layers (21, 22, 23, 24) are the following thicknesses under a condition which a design wave length λ_0 is within 450 - 550 nm;

10 First layer; 0.05 - 0.15 λ_0 ,
 Second layer; 0.05 - 0.15 λ_0 ,
 Third layer; 0.36 - 0.49 λ_0 , and
 Fourth layer; 0.15 - 0.35 λ_0 .

19. A modification of the light-transmissible plate according to any one of claims 15 to 18, wherein the first and second layers are combined into a single layer.

20. A light-transmissible plate according to any one of claims 15 to 19, wherein the layers of anti-reflection coating are films formed by evaporation coating.

21. A light-transmissible plate according to any one of claims 15 to 19, wherein the layers of anti-reflection coating applied to the hard coating layer (2') are films formed by sputtering.

22. A light-transmissible plate according to any preceding claim, wherein said light-transmissible plate is an optical filter for a cathode-ray tube.

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FIG. 2

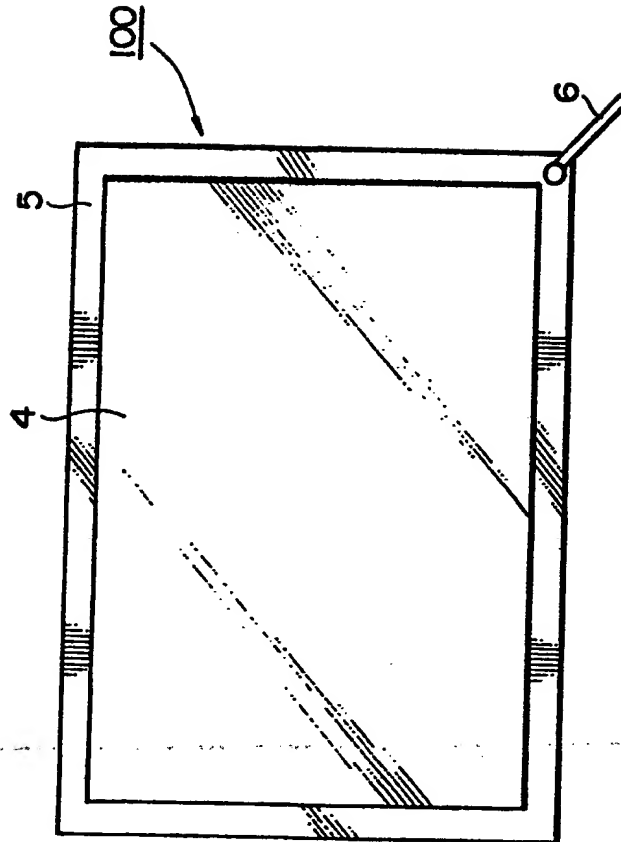
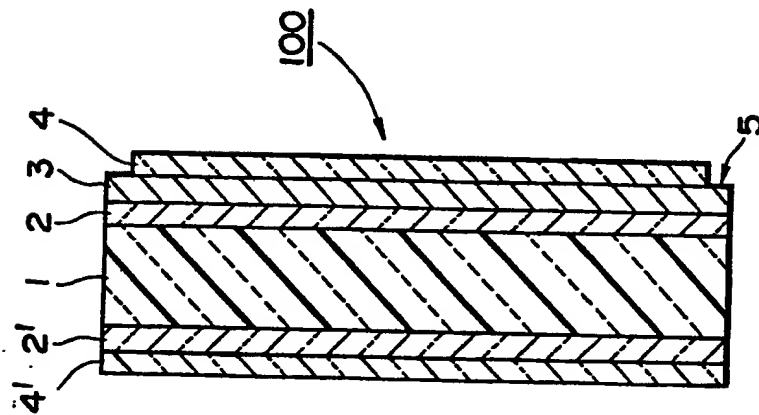


FIG. 1



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FIG. 3

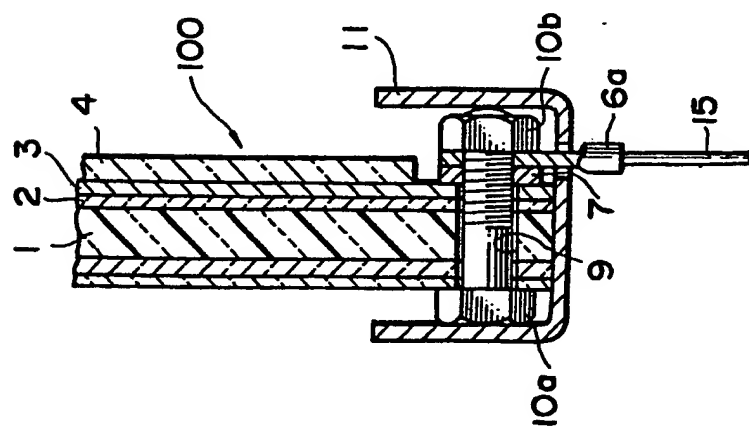


FIG. 4

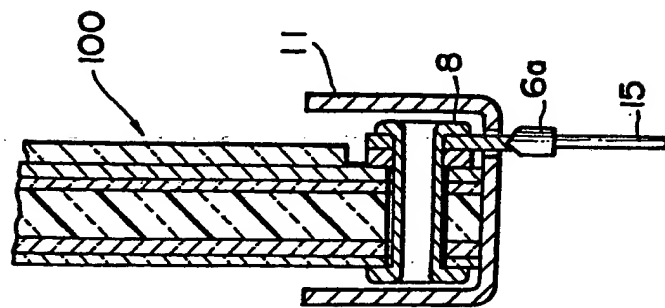


FIG. 5

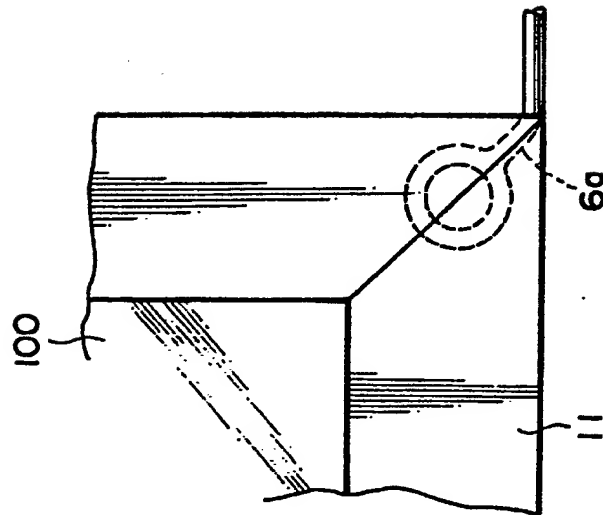


FIG. 8

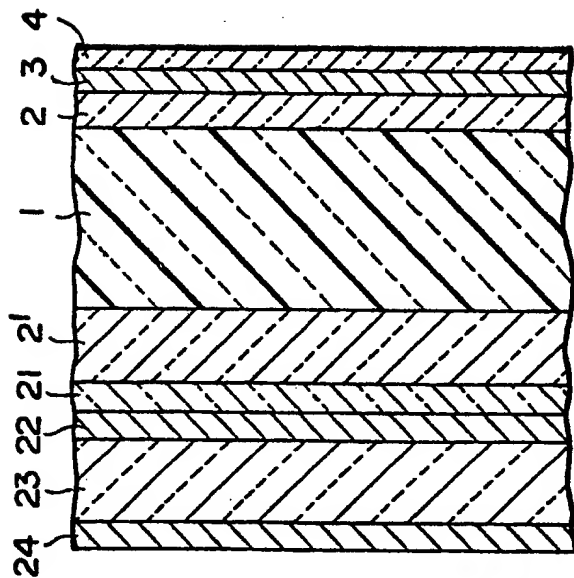


FIG. 7

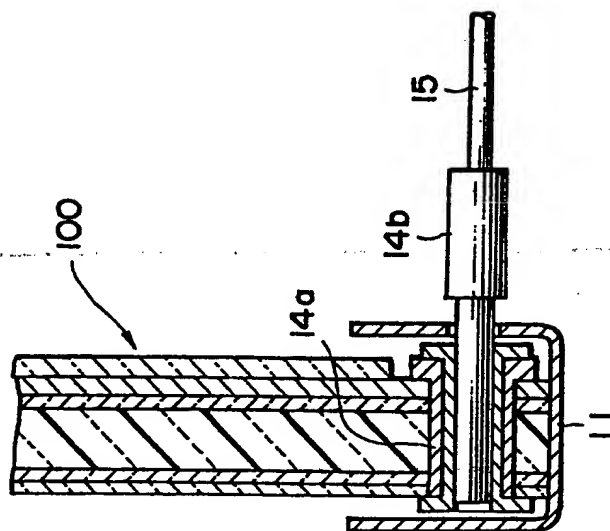


FIG. 6

